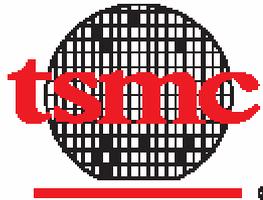


# Key Methods in Reducing Pad Void Formation and Experimental Result



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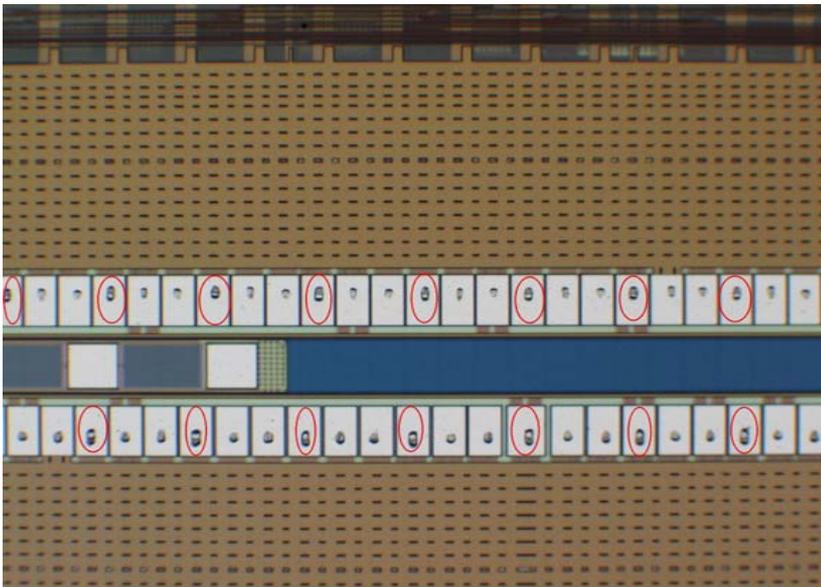
Wensen Hung

# Agenda

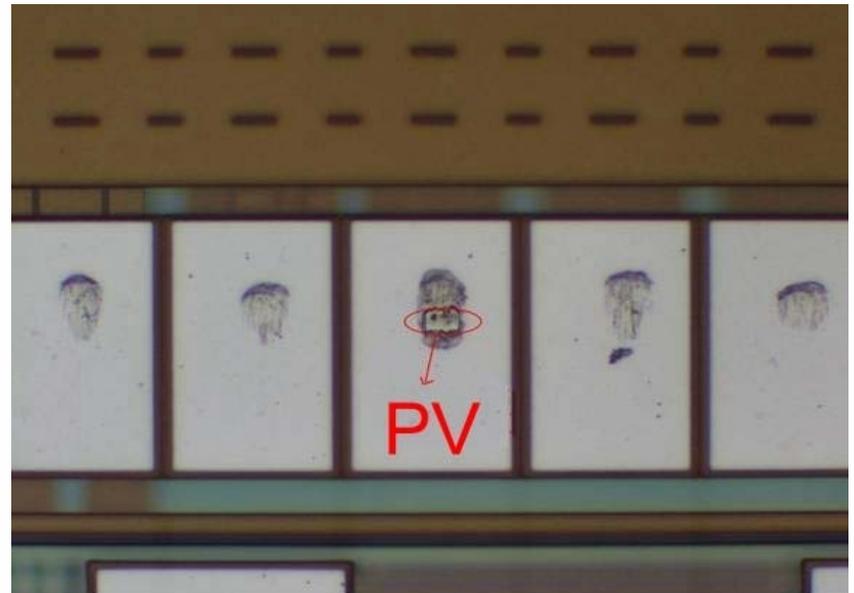
- **Pad Void (PV) cases at TSMC mass production pipeline**
- **Theoretical and FEA**
- **DOE with Taguchi Method**
  - ✓ Experiment I
  - ✓ Experiment II
- **Scrub Depth Model Formulation (SDMF)**
  - ✓ Theory, Experiment and Verification
- **Conclusion**

# PV Case in TSMC Case1

- Problem description
  - Pad void by 1<sup>st</sup> layer needle



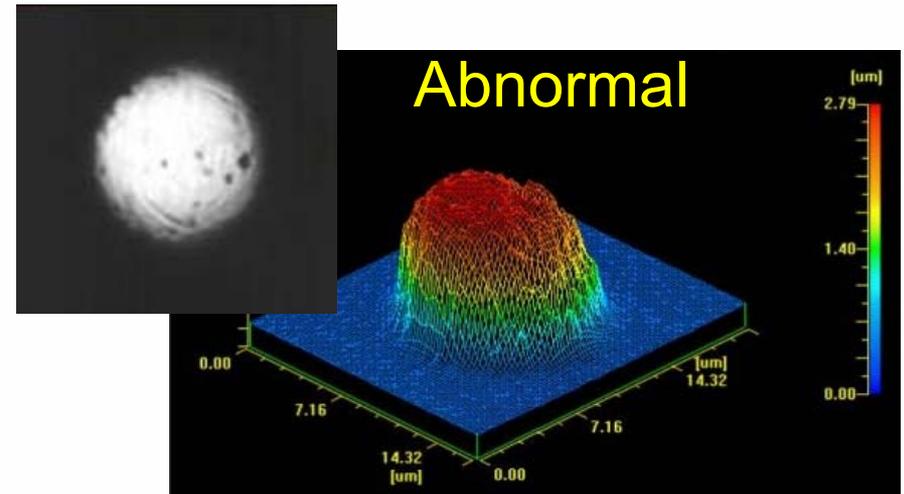
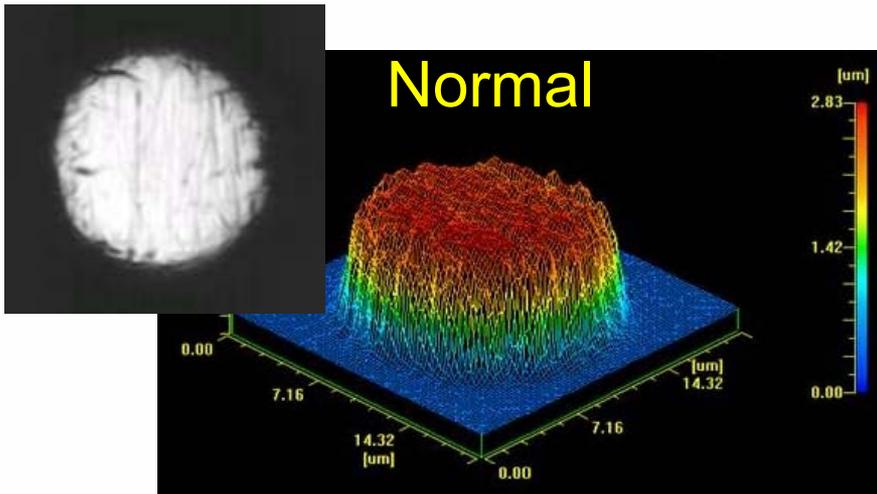
Repeated PV patterns



# PV Case in TSMC Case1 Cont.

## ● Analysis

- CSLM\* 3D scanning of tip profile revealed that tip diameter was shaped into smaller and sharper .
- This is attributed to abnormal phenomenon of needle.



**Solution: Sanding and repairing tip profile**

# PV Case in TSMC Case2

## ● Problem description

- PV occurred as underlying pad exposed after 670k tds
- Different probers were used for this card.
- But other cards were free of PV issues.

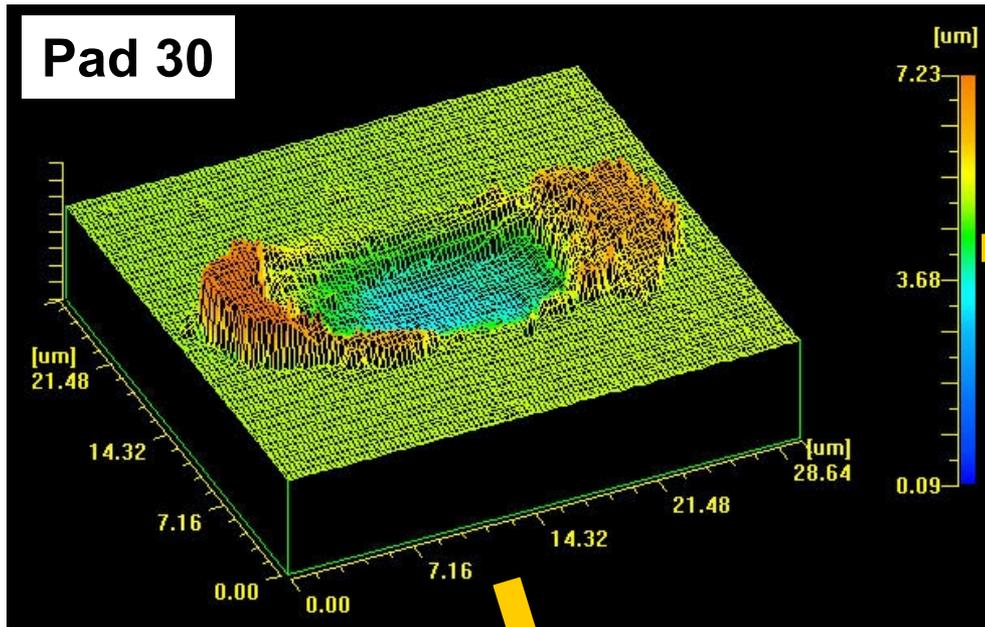
## ● Analysis

- PV cases occurred only at 1st layer groups.
- Chuck speed was found too high for different prober set up.

Layer	Pad No.
1	3,6,9,12,18,30 21,33
2	4,7,10,16,19,29,32
3	5,8,11,17,20,28,31



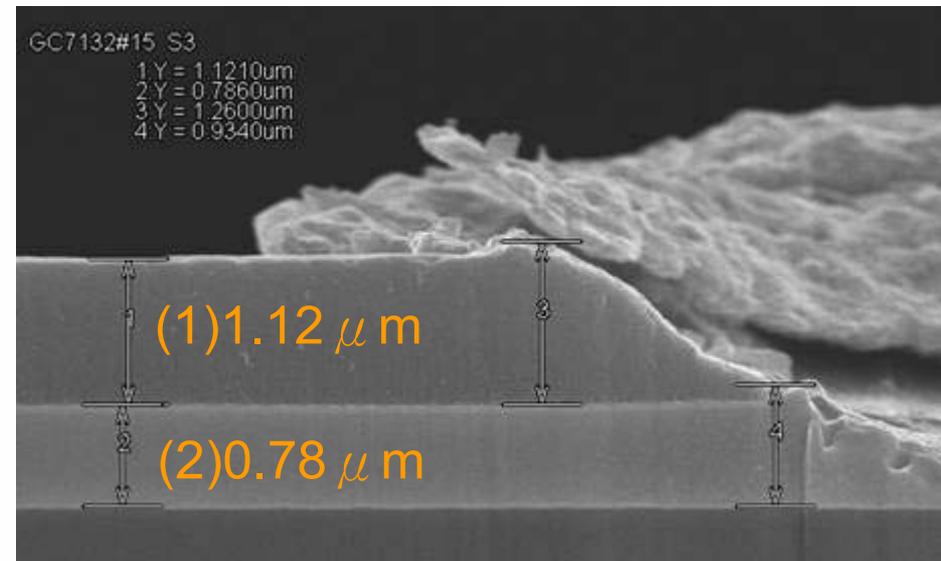
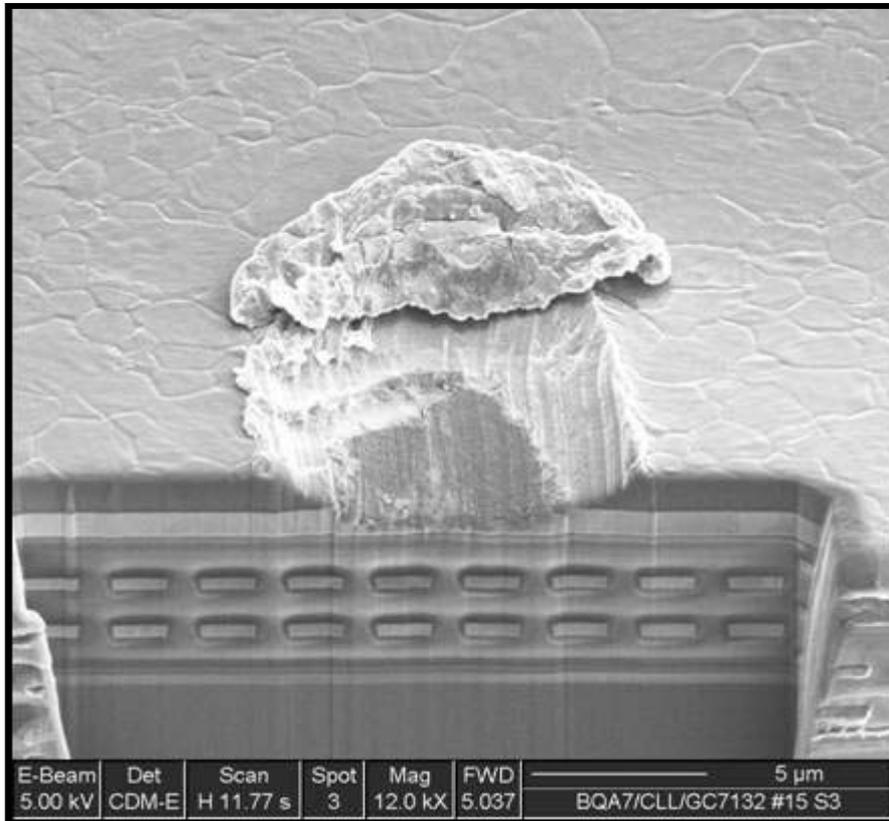
# PV Case in TSMC Case2 Cont.



**Unbelievable!**

maximum scrub depth up to  $1.7\mu\text{m}$  resulted from 1<sup>st</sup> time tds.

# PV Case in TSMC Case2 Cont.



- SEM micrographs and measurements showed the actual scrub depth of 1.7  $\mu$ m.

**Solution: Reduce Chuck Speed**

# PV Case in TSMC Summary

- Key causes from collected mass-productions' PV cases:
    - Smaller or sharper tip shape
    - Excessive contact force
    - Higher chuck speed set up
    - Old probe cards used after a longer period of time
    - PV cases mostly at 1st layer group needles
    - Deepest scrub depth sites of PVs measured mostly at initial touched region
  - PV cases prompt to big revenue loss, thus preventive efforts needed in advance are:
    - “PV causes search” and “scientific prediction works”
- These learnings could be good references for probe card specs. establishment and also as prober set up procedures.

# Theoretical and FEA

- **Analysis of Root-Cause Factors**

$$F_y = K_{yy} D_y \quad \text{Common definition of BCF}$$

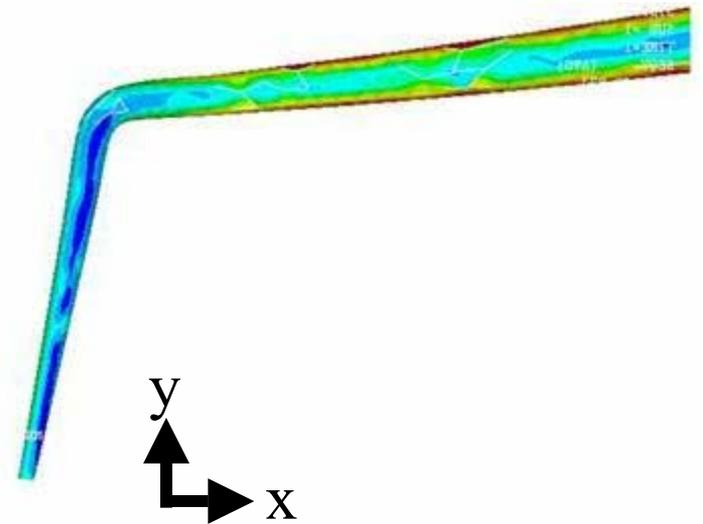
$$F_i = K_{ij} D_j \quad \text{General definition of Contact Force}$$

$i$  : direction of overtravel force

$j$  : direction of resulted displacement

$K_{ij}$ : needle stiffness

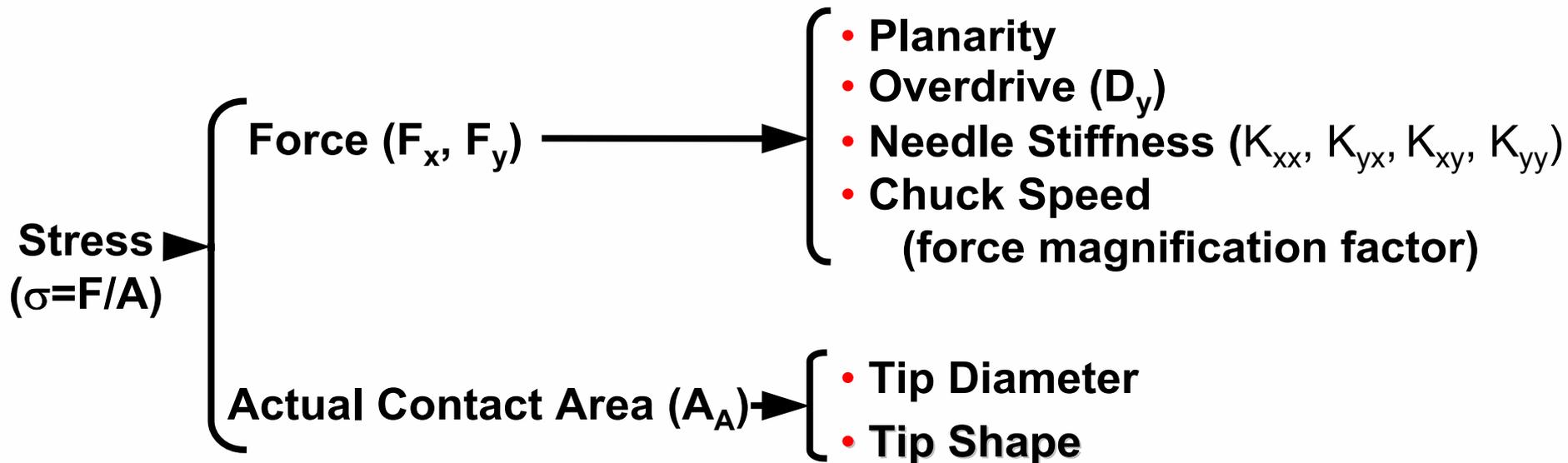
$D_j$ : displacement



# Theoretical and FEA Cont.

Pad damage quantitatively also refers to “STRESS” induced at pad.

Thus, “STRESS” could be determined by main factors, such as:

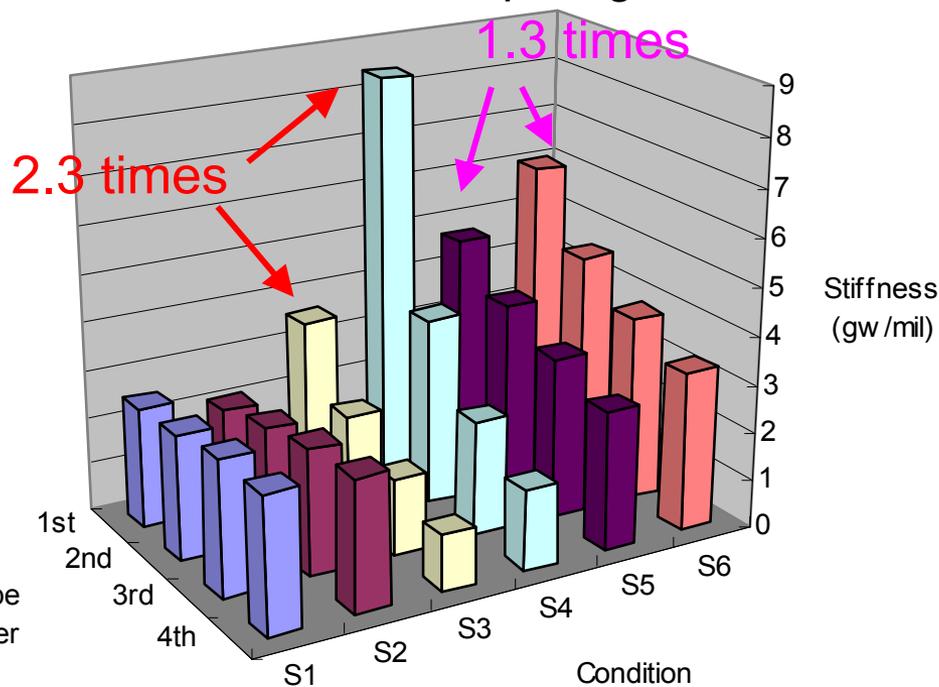


# Theoretical and FEA Cont.

Item		gw/ mil	Needle Tier			
			1st	2nd	3rd	4th
Stiffness (Kyy)		PRVX*	2.20	2.34	2.43	2.62
		FEA*	2.28	2.37	2.67	2.75
PRVX / FEA (Kyy)			96%	99%	91%	95%
FEA	Tip Length 1st tier = 10mils	Kxx	3.61	2.23	1.60	1.17
		Kyy	2.49	2.63	2.83	2.84
		Kxy=Kyx	4.74	3.88	3.35	2.88
	Tip Length 1st tier = 7.5mils *	Kxx	5.17	2.83	1.94	1.47
		Kyy	2.28	2.37	2.67	2.75
		Kxy=Kyx	4.98	3.81	3.36	2.97
	Tip Length 1st tier = 5mils	Kxx	8.43	3.91	2.39	1.68
		Kyy	2.10	2.37	2.61	2.72
		Kxy=Kyx	6.03	4.61	3.87	3.32

# Theoretical and FEA Cont.

Variation of stiffness in X and Y direction with different tip lengths



- Reducing tip length would not vary the probe stiffness  $K_{yy}$ . (see graph S1 & S2)
- Reducing tip length 10 mil to 5 mil at 1<sup>st</sup> layer needles, needle stiffness  $K_{xx}$  radically changed from 3.61 gw/mil into 8.43 gw/mil, magnified by **2.3 times**. (see graph S3 & S4)
- Reducing tip length 10 mil to 5 mil at 1<sup>st</sup> layer needles, stiffness  $K_{xy}$  or  $K_{yx}$  changed from 4.74 gw.mil into 6.03 gw/mil, magnified by **1.3 times**. (see graph S5 & S6)



# Experiment I

- **Control factors and their range of settings for the experiment**

- Tip Length                   ⇒ 5 and 9 mils
- Tip Angle                    ⇒ 100° and 106°
- Needle Diameter          ⇒ 6 and 10 mils
- Stiffness,  $K_{yy}$            ⇒ 2 and 3.3 gw/mil
- Tip Diameter                ⇒ 0.5 and 1 mil

Fix factor !  
1st layer needle

Sample No.	Tip length (mil)	Tip angle (Degree)	Needle Dia. (mil)	Stiffness (gw/mil)	Tip Dia. (mil)
1	5	100	6	2	0.5
2	5	100	10	3.3	1.0
3	5	106	6	2	1.0
4	5	106	10	3.3	0.5
5	9	100	6	3.3	0.5
6	9	100	10	2	1.0
7	9	106	6	3.3	1.0
8	9	106	10	2	0.5

Table of Taguchi experimental factors

# Experiment I Cont.

## ● Analysis and Result

- Carried out repeated tds on same pad to observe PV.
- Sample 4 indicated PV occurrence at 2<sup>nd</sup> tds.  
(remarked as 100 pts count)
- PV appeared after 11<sup>th</sup> times probing for sample 7.

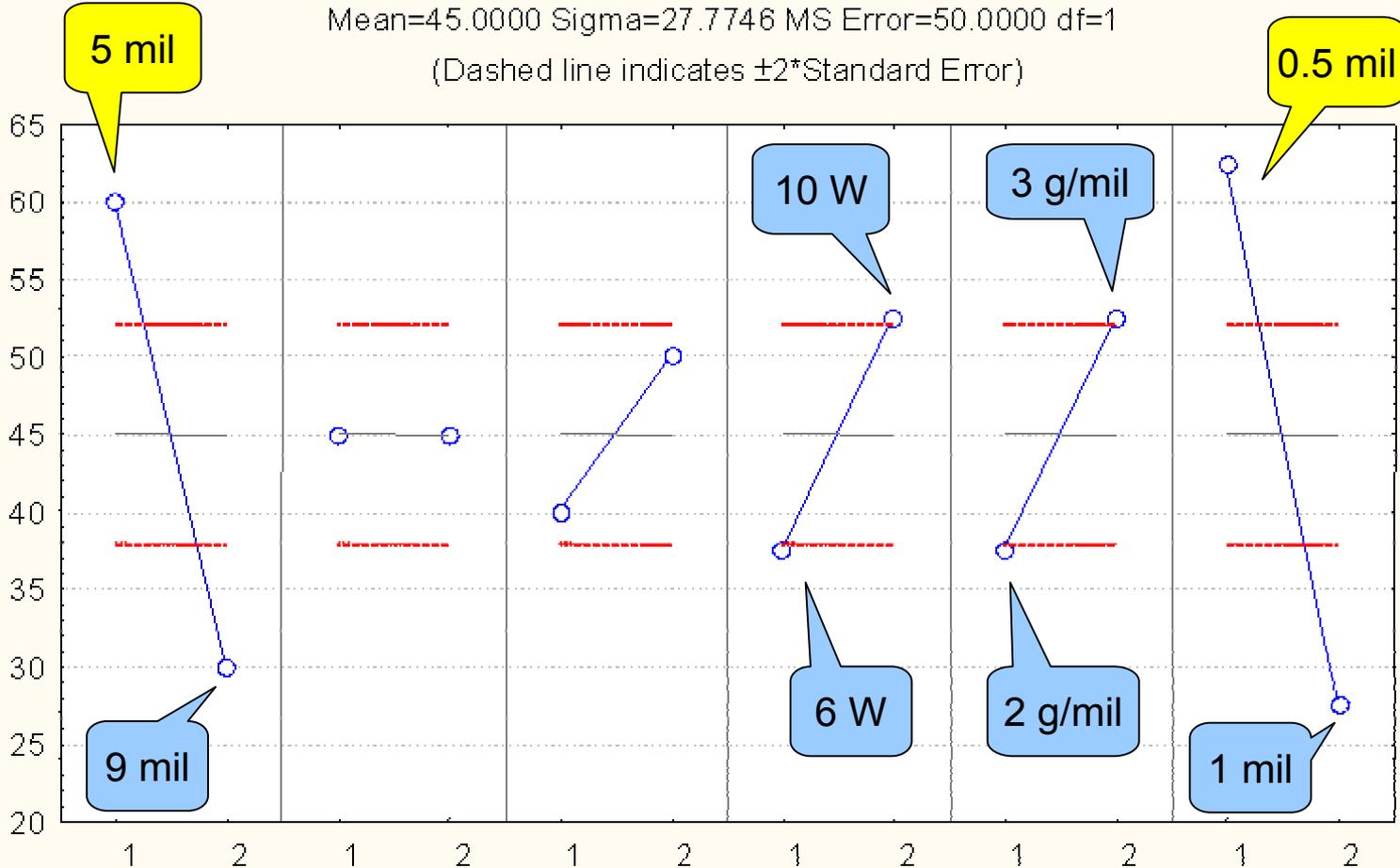
Sample No.	TD x1	TD x2	TD x3	TD x4	TD x5	TD x6	TD x7	TD x8	TD x9	TD x10	TD x11	Count
1						pv	pv	pv	pv	pv	pv	60
2							pv	pv	pv	pv	pv	50
3									pv	pv	pv	30
4		pv	pv	100								
5							pv	pv	pv	pv	pv	50
6										pv	pv	20
7											pv	10
8								pv	pv	pv	pv	40

# Experiment I Cont.

Average Eta by Factor Levels

Mean=45.0000 Sigma=27.7746 MS Error=50.0000 df=1

(Dashed line indicates  $\pm 2$  \* Standard Error)



Short  
Tip Length  
+  
Small  
Tip Dia.  
+  
Large  
Stiffness  
+  
Thick  
Needle Dia.  
↓  
Pad Void

Tip Length	Tip Angle	Interaction	Needle Dia.	Stiffness	Tip Dia.
------------	-----------	-------------	-------------	-----------	----------

User-defined S/N Ratio

# Experiment II

## ● Design of Experiment

Inner  
orthogonal  
array

Control Factor	Sample	$K_{yy}$ (gw/mil)	Tip Dia.(mil)	Tip Length(mil)
	1	1.5	0.4	4
	2	1.5	0.7	7
	3	1.5	1	10
	4	3	0.4	7
	5	3	0.7	10
	6	3	1	4
	7	4.5	0.4	10
	8	4.5	0.7	4
	9	4.5	1	7

Outer  
orthogonal  
array

Noise	Temperature( $^{\circ}$ C)	25	25	85	85
	Overdrive(mil)	1.5	4	1.5	4

# Experiment II Cont.

## ● How to execute:

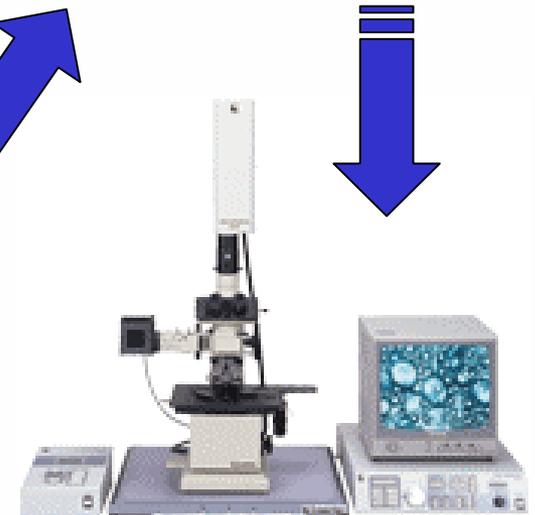


1. Prepare Dummy Wafers

	Sample
P/C 1	1、6、8
P/C 2	1、6、8
P/C 3	2、4、9
P/C 4	2、4、9
P/C 5	3、5、7
P/C 6	3、5、7

2. Build 3 samples in one piece of P/C

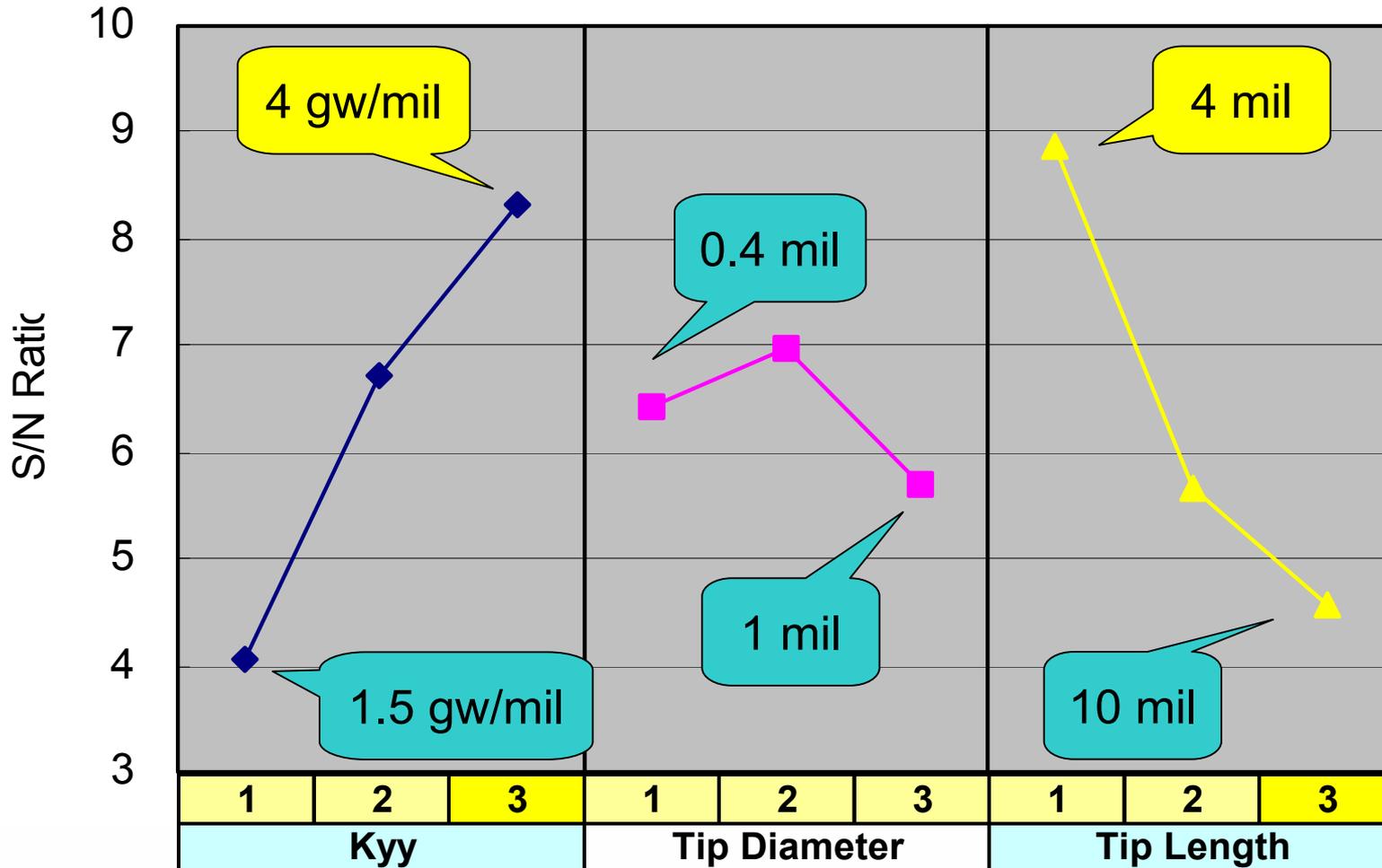
3. Probe Wafer with Different Conditions



4. Measure Scrub Depth

# Experiment II Cont.

S/N Ratio of 2nd Experiment



# Summary of Experiment I & II

- By choosing all critical parameters, a two-level L8 orthogonal array experiment I has been performed, the influential factors have been determined as follow:
  - Primary dominant factors → **tip length, tip diameter**
  - Secondary dominant factors → stiffness  $K_{yy}$ , tip diameter
- From TSMC mass production testing, three critical parameters were chosen to perform experiment II with a L9 three-level setting. The summarized results are:
  - Primary dominant factors → **tip length, stiffness  $K_{yy}$**
  - Secondary dominant factors → tip diameter
- The slight variation in results of these two experiments, it was recognized that these experiments still had uncontrolled noise.
- It is concluded that these two experiments indicated that **tip length, tip diameter, stiffness  $K_{yy}$**  were the three most influential primary parameters.

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

- **Recall Ref. #1, Assumption:**

Uniform normal stress, no frictional force, thus scrub depth of Point Cobra Probe can be described as

$$\bar{U}_{z_a} = \frac{4(1-\nu^2)F}{\pi^2 E a}$$

$$(\bar{U}_{z_a} = \frac{2}{\pi} \cdot \bar{U}_{z_0})$$

$$\bar{U}_{z_0} = \frac{2(1-\nu^2)F}{\pi E a}$$



wherein  $F = K \cdot \delta$

$\delta$ : Overdrive

$K$ : Stiffness (spring constant)

$F$ : Balanced contact force

$E$ : Equivalent modulus of elasticity of pad

$a$ : Probe tip radius

$\nu$ : Poisson's ratio

$\bar{U}_{z_0}$ : Scrub depth at center

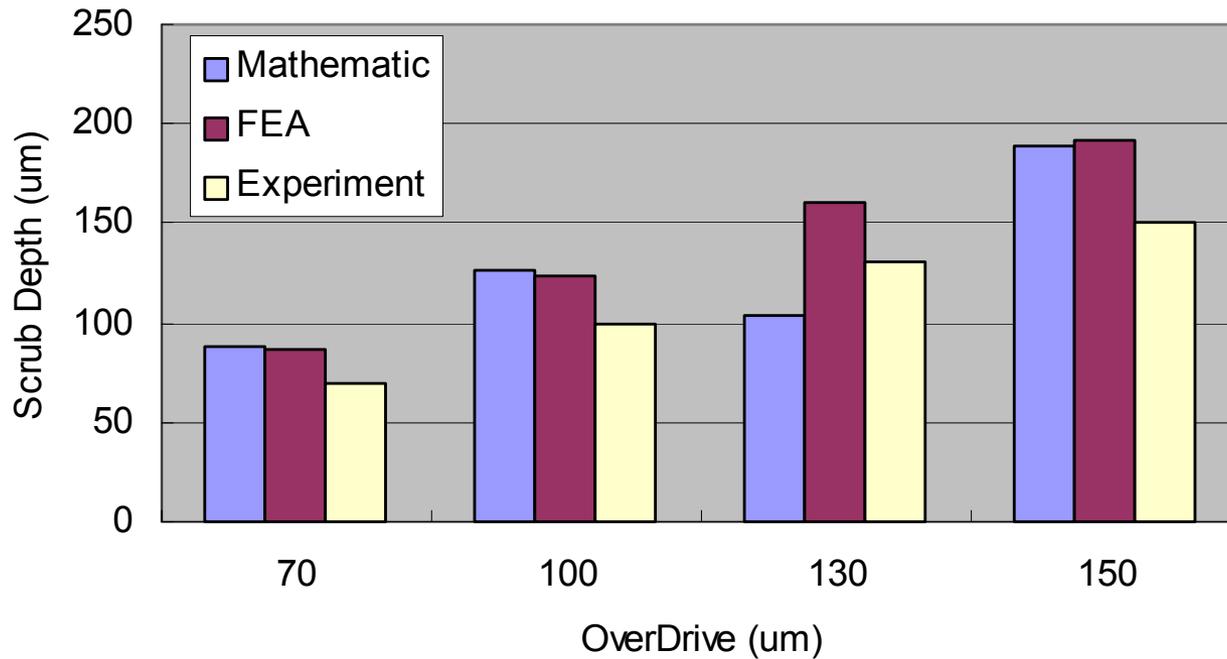
$\bar{U}_{z_a}$ : Scrub depth around

#1 Chen, K. M., 2003, "A Study of Microelectronics Probing Depth and Electromigration Effect of Solder Bump," Ph.D. Dissertation, Department of Power Mechanical Engineering, University of Tsing Hua in Taiwan.

# Scrub Depth Model Formulation (SDMF)

## Theory, Experiment and Verification

Scrub Depth of Experiment, FEA and Mathematic Method  
(source: Ref. #.1)



But!  
Cantilever Type Needle  
is more complex

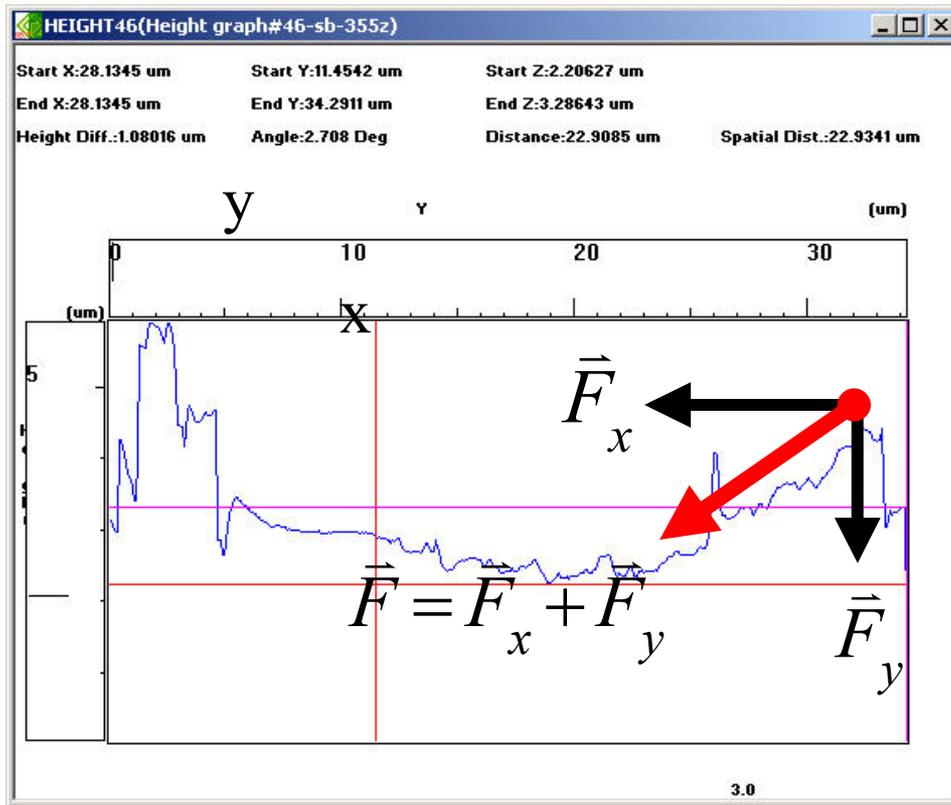
Correlation between theoretical and experimental is 4.6%~6% which evidently implied that simply a normal pressure the scrub depth is quantitatively predictable.

#1 Chen, K. M., 2003, "A Study of Microelectronics Probing Depth and Electromigration Effect of Solder Bump," Ph.D. Dissertation, Department of Power Mechanical Engineering, University of Tsing Hua in Taiwan.

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

- SDMF of cantilever type needle:



Assumption:

Matrix of **initial** contact force on pad as follow :

$$\begin{bmatrix} F_x \\ F_y \end{bmatrix} = \begin{bmatrix} K_{xx} & K_{xy} \\ K_{yx} & K_{yy} \end{bmatrix} \begin{bmatrix} D_x \\ D_y \end{bmatrix}$$

$i$  : direction of overtravel force

$j$  : direction of resulted displacement

$K_{ij}$ : needle stiffness

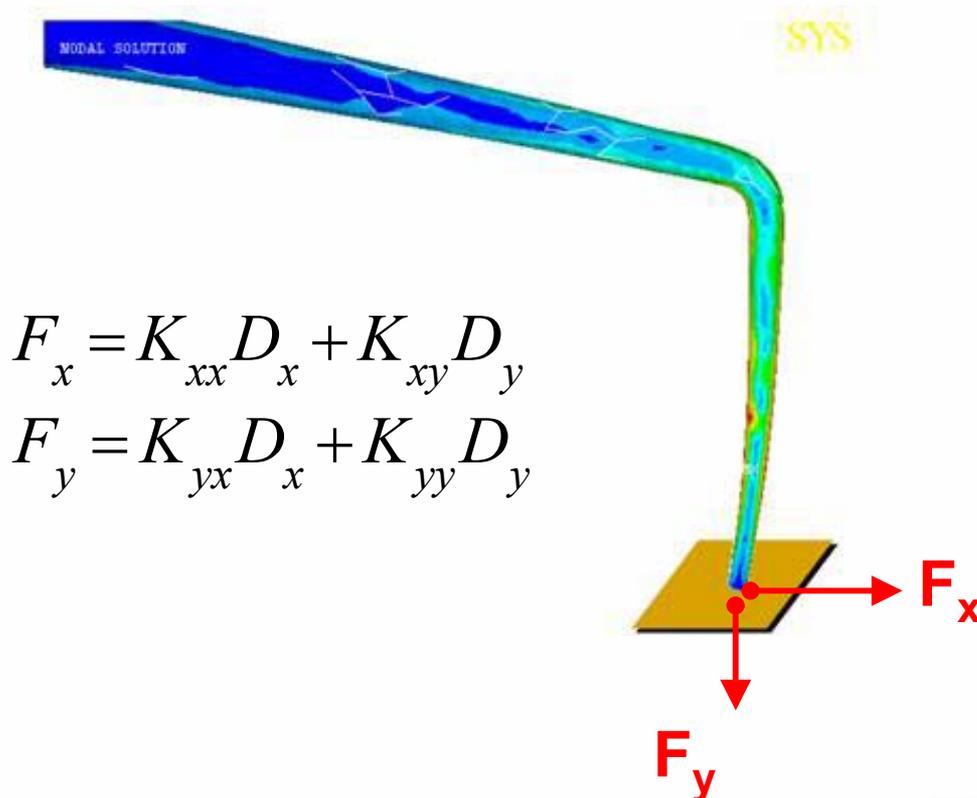
$D_j$ : displacement

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

- **SDMF of cantilever type needle:**

Contact force vector  $F$  is rectangular component vector of  $F_x$  &  $F_y$



$$F_x = K_{xx} D_x + K_{xy} D_y$$

$$F_y = K_{yx} D_x + K_{yy} D_y$$

Recall:

For Cobra point tip needle:

$$D_x \cong 0 \quad \therefore F_y = K_{yy} \times D_y$$

For present SDMF of cantilever needle:

$$F_y = K_{yx} D_x + K_{yy} D_y$$

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

**Assumption:**

- (1) Scrub depth is governed by  $F_y$
- (2) Pad material properties based on standard TSMC processes

Thus,

$$\bar{U}_z = C \times \frac{F_y}{D} \quad \text{where} \quad \begin{array}{l} \bar{U}_z : \text{Max. Scrub Depth} \\ C \ \& \ B : \text{Constant} \\ D : \text{Tip Diameter} \end{array}$$

Then, assume:

$$D_x = B D_y$$

Thus,

$$\begin{aligned} F_y &= K_{yx} D_x + K_{yy} D_y = K_{yx} B D_y + K_{yy} D_y \\ &= (K_{yx} B + K_{yy}) D_y \end{aligned}$$

$$\therefore \bar{U}_z = C \times (K_{yx} B + K_{yy}) \frac{D_y}{D}$$

$K_{yx}$  could be solved by FEA, and correlate with experimental works to find the correct value of C & B.

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

- **How to Execute:**
  - Parameter Selection

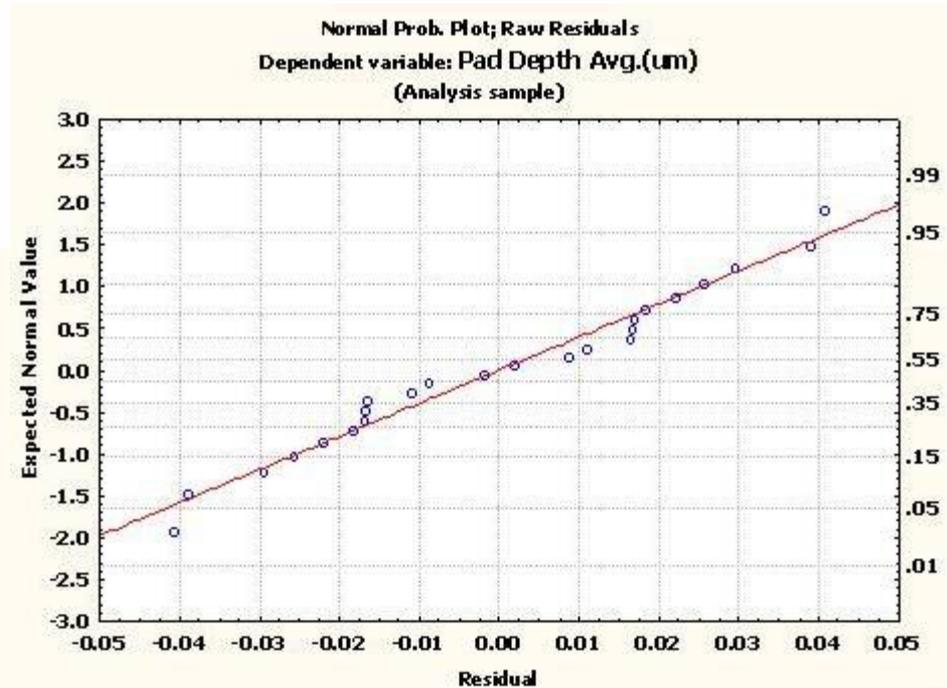
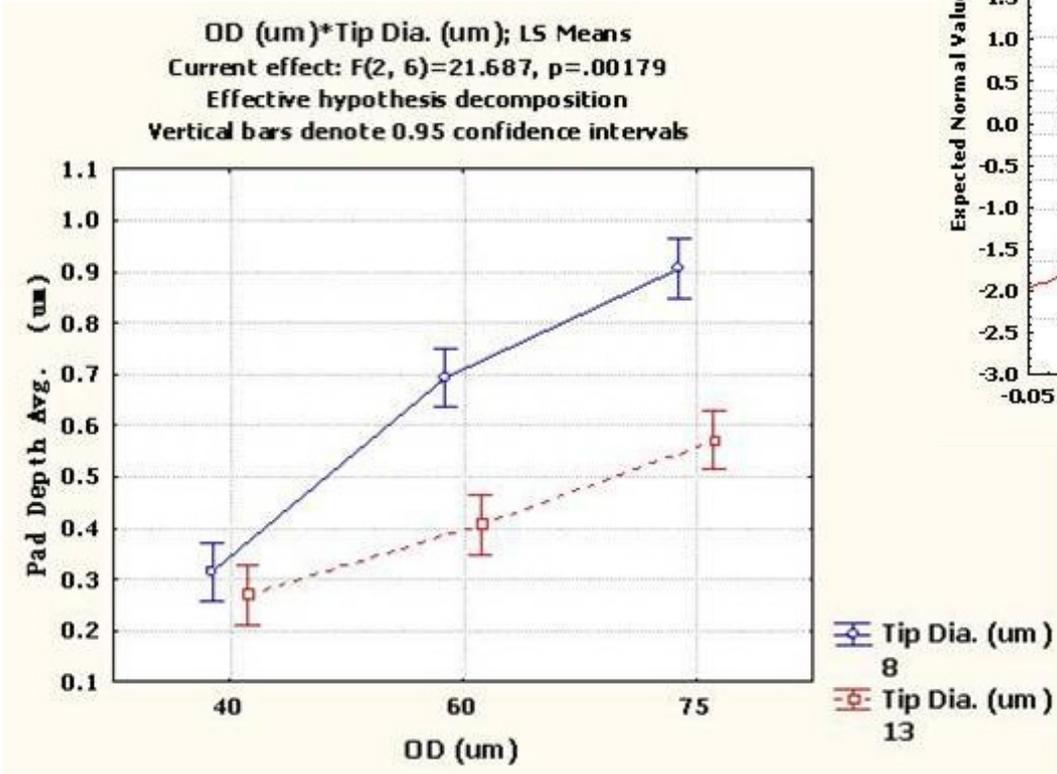
Parameter	Spec.
Tip Dia.(um)	8 , 13
OD(um)	40 , 60 , 75
Kyy(gw/mil)	2.5
Needle Dia. (mil)	5
Tip Length (mil)	7.5 , 11.5 , 15.5 , 19.5

- Pick up one production wafer as probing test.
- Five pads were used to determine each interested parameters and measured scrub depth.

# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

## ● Result and Analysis:



According to the residual plot, it showed the experimental works are in agreement with the **normal distribution** pattern.

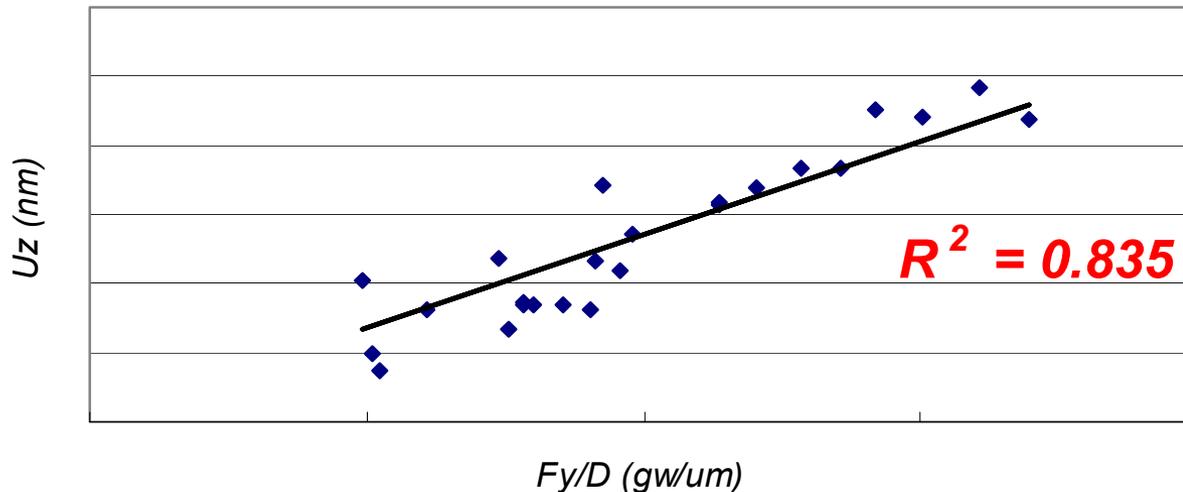
# Scrub Depth Model Formulation (SDMF)

Theory, Experiment and Verification

- Constant values B & C were found from curve fitting.

$$\begin{aligned}\bar{U}_z &= C \frac{F_y}{D} \\ &= C(BK_{yx} + K_{yy}) \frac{D_y}{D}\end{aligned}$$

**Curve Fitting Result**



Unit :

$\bar{U}_z$  : nm

$K_{yx}, K_{yy}$  : gw/mil

$D_y$  : mil

$D$  :  $\mu\text{m}$

# Conclusion

- ❑ PV occurrence has been one of the most troublesome issue for mass production processes.
- ❑ Key learnings from TSMC PV cases: reducing stiffness, sanding tip into larger diameter, and lowering chuck speed.
- ❑ Three primary dominant factors determining the scrub depth are stiffness, tip length and tip diameter.
- ❑ Scrub Depth Model Formulation (SDMF) was established and proven as an useful engineering method for preventing PV. This worth-noted innovative works still need more comprehensive verification works.

# Follow-On Works ...

- ❑ SDMF verification for different needle diameters.
- ❑ SDMF verification for different chuck speed to determine the exact range of constant values.
- ❑ Verification works by utilizing wafers, particularly built from different processes, and assigned by different testing conditions.